

N-Channel Enhancement MOSFET

Features

- Drain-Source Breakdown Voltage V_{DSS} -20 V
- Drain-Source On-Resistance $R_{DS(ON)}\,82m\Omega,\,at\,\,V_{GS}=10V,\,I_{D}=2.6A$ $R_{DS(ON)}\,96m\Omega,\,at\,\,V_{GS}=4.5V,\,I_{D}=2.1A$
- Continuous Drain Current at T_C=25°C I_D = 2.6A
- Advanced high cell density Trench Technology
- RoHS Compliance & Halogen Free

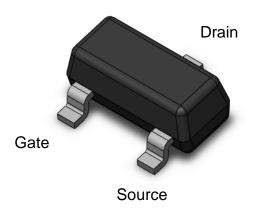
Applications

- Power Management
- Lithium Ion Battery

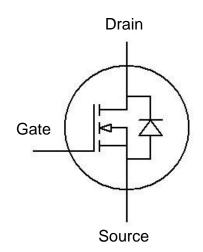
Description

The CTL0266NS-R3 is the N-Channel logic enhancement mode power field effect transistors are produced using high cell density, DMOS trench technology. This high density process is especially tailored to minimize on-state resistance. These devices are particularly suited for low voltage application such as cellular phone and notebook computer power management and other battery powered circuits where high-side switching and low in-line power loss are needed in a very small outline surface mount package.

Package Outline



Schematic





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Absolute Maximum Rating at 25°C

Symbol	Parameters	Test Conditions	Min	Notes
VDS	Drain-Source Voltage	60	V	
Vgs	Gate-Source Voltage	±20	V	
lσ	Continuous Drain Current	2.6	Α	1
Ірм	Pulsed Drain Current	10	Α	1
PD	Total Power Dissipation	1.04	W	2
Тѕтс	Storage Temperature Range	-55 to 150	°C	
TJ	Operating Junction Temperature Range	-55 to 150	°C	

Thermal Characteristics

Symbol	Parameters	Test Conditions	Min	Тур	Max	Units	Notes
R⊕JA4	Thermal Resistance			110		00 444	4.4
К ӨЈА4	Junction-Ambient (t=10s)			110		°C W	1,4



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Electrical Characteristics $T_A = 25$ °C (unless otherwise specified)

Static Characteristics

Symbol	Parameters	Test Conditions	Min	Тур	Max	Units	Notes
Bvdss	Drain-Source Breakdown Voltage	Vgs= 0V, ID= -250µA	60	-	-	V	
IDSS	Drain-Source Leakage Current	VDS = 60V, VGS = 0V	-	-	-1	μА	
lgss	Gate-Source Leakage Current	Vgs = ±20V, Vps = 0V	-	-	±100	nA	

On Characteristics

Symbol	Parameters	Test Conditions	Min	Тур	Max	Units	Notes
D	Drain-Source On-Resistance	$V_{GS} = 10V, I_D = 2.6A$	-	82	100	mΩ	2
Rds(ON)	Drain-Source On-Resistance	Vgs = 4.5V, ID = 2.1A	-	96	130	mΩ	3
VGS(th)	Gate-Source Threshold Voltage	V _G S = V _D S, I I _D =-250μA	1.0		3.0	V	3

Dynamic Characteristics

Symbol	Parameters	Test Conditions	Min	Тур	Max	Units	Notes
Ciss	Input Capacitance	Vgs =0V,	-	350	-		
Coss	Output Capacitance	Vps =30V	-	40	-	pF	
Crss	Reverse Transfer Capacitance	f=1MHz	-	12	-		

Switching Characteristics

Symbol	Parameters	Test Conditions	Min	Тур	Max	Units	Notes
T _{D(ON)}	Turn-On Delay Time	V _{DS} = 20V,	-	10	-		
TR	Rise Time	$V_{GS} = 10V$,	-	11	-		
T _D (OFF)	Turn-Off Delay Time	$R_G = 1\Omega$,	-	29	-	ns	
T _F	Fall Time	$R_L=20\Omega$,	-	3	-		
Q _G	Total Gate Charge	V _{DS} = 30V ,	-	6.5	-		
Qgs	Gate-Source Charge	V _{GS} = 4.5V,	-	2.2	-	nC	
Q _{GD}	Gate-Drain Charge	I _D = 2.6A	-	2.7	-		



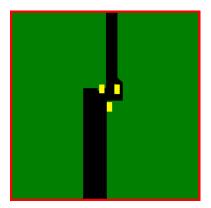
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Drain-Source Diode Characteristics

Symbol	Parameters	Test Conditions	Min	Тур	Max	Units	Notes
VsD	Body Diode Forward Voltage	Vgs = 0V, ID = 1A	-	0.8	1.2	V	
Isp	Body Diode Continuous Current		-	-	2.1	Α	1

Note:

- 1. The power dissipation is limited by 150°C junction temperature.
- 2. Device mounted on a glass-epoxy board



FR-4

25.4 × 25.4 mm.

2 Oz Copper

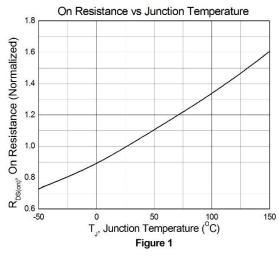
Test Board

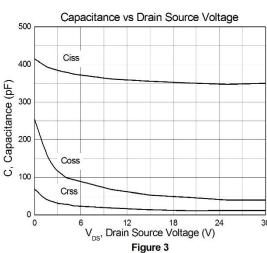
- 3. The data tested by pulsed , pulse width $\leq 300 \mu s$, duty cycle $\leq 2\%$
- 4. Thermal Resistance follow JESD51-3.

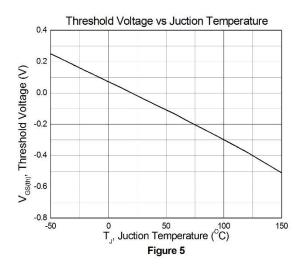


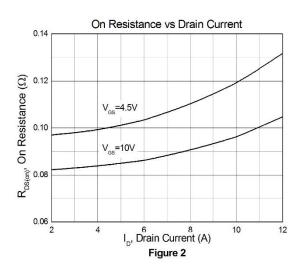
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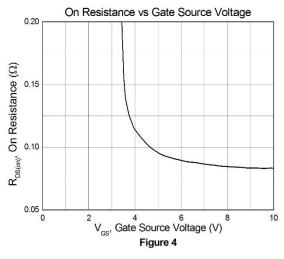
Typical Characteristic Curves

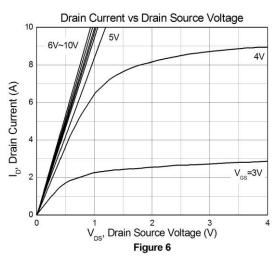






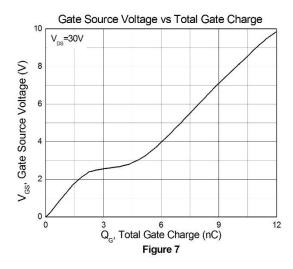


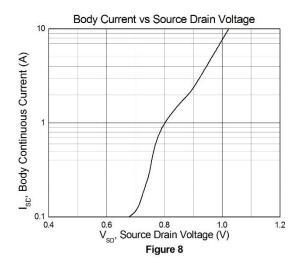






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Test Circuits & Waveforms

Figure 12: Gate Charge Test Circuit

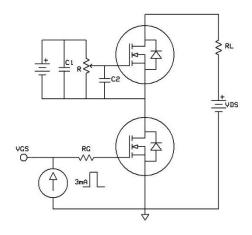


Figure 14: Switching Time Test Circuit

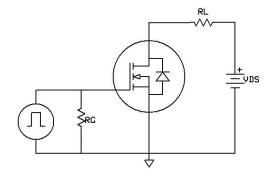


Figure 13: Gate Charge Waveform

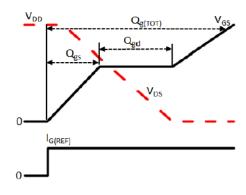
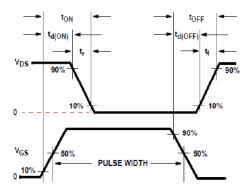


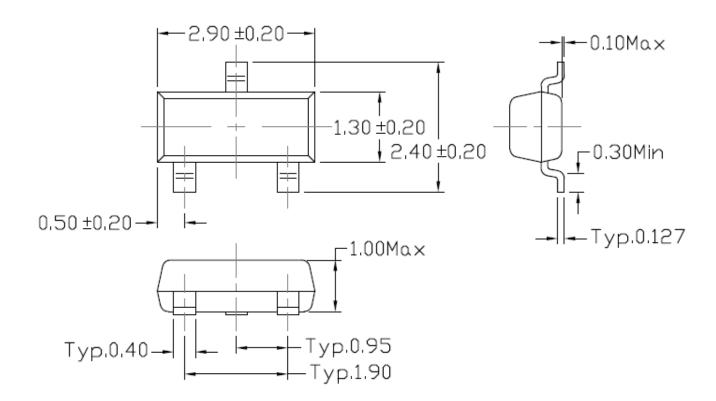
Figure 15: Switching Time Waveform



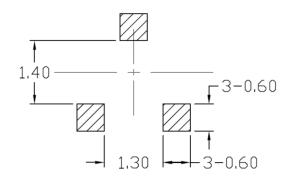


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Package Dimension (SOT-23)



Recommended pad layout for surface mount leadform

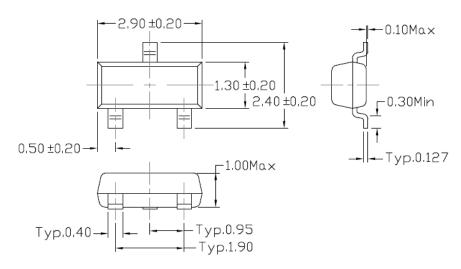




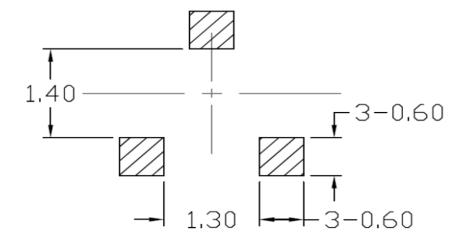


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Package Dimension Dimensions in mm unless otherwise stated

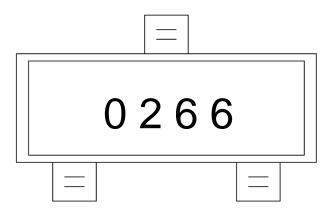


Recommended pad layout for surface mount leadform



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Marking Information



0266: Device Number

Ordering Information

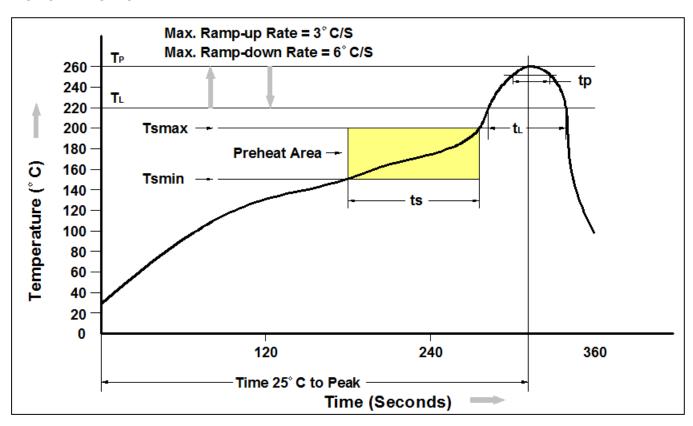
Part Number	Description	Quantity
CTL0266NS-R3	SOT-23 Reel	3000 pcs





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Reflow Profile



Profile Feature	Pb-Free Assembly Profile
Temperature Min. (Tsmin)	150°C
Temperature Max. (Tsmax)	200°C
Time (ts) from (Tsmin to Tsmax)	60-120 seconds
Ramp-up Rate (t∟ to t⊳)	3°C/second max.
Liquidous Temperature (T _L)	217°C
Time (t _L) Maintained Above (T _L)	60 – 150 seconds
Peak Body Package Temperature	260°C +0°C / -5°C
Time (t _P) within 5°C of 260°C	30 seconds
Ramp-down Rate (T _P to T _L)	6°C/second max
Time 25°C to Peak Temperature	8 minutes max.



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